NUMERICAL ANALYSIS OF ULTRATHIN CIGS WITH SI AS ABSORBER LAYER WITH SCAPS-1D SIMULATOR

Abstract

The paper reports on the performance of ultrathin CIGS photovoltaic cells. New structure had been proposed with the help of SCAPS-1D simulator. The prime aim of this analysis is to improve device performance and reduce material cost as compared to conventional CIGS solar cells. For this purpose p Si of 1um had been inserted. CIGS thickness was ranging from 0.1 um to 1um. It could be verified with simulation result that improvement of absorber with layer thickness performance of cell also improved. The best conversion efficiency 19.56% obtained with ZnO of thickness 0.02um, CdS thickness of 0.05 um CIGS layer thickness of 1um and Si layer of thickness of 1um respectively.

Key words: CIGS, SCAPS-1D, ultrathin layer, Solar cell, simulation.

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I. INTRODUCTION

Photovoltaic cells based on CIGS are promising materials because it has an advantage of covering wide range of solar radiation spectrum. This diminishes the material costs and shows excellent performance as compared to silicon based solar cells. CIGS is very important material for thin film solar cell because of its many advantages such as high absorption coefficient and suitable band gap. Its efficiency had been reported 20.4% previously [8].The only demerit is high cost of gallium and indium. In order to overcome this shortcoming it is necessary to bring down thickness of CIGS layer so the use of gallium and indium can be reduced [8]. In present work alternative CIGS structure was suggested. SCAPS-1D was used to investigate the performance of new ultrathin CIGS solar cell. The performance of cell was observed by inserting new absorber layer p-Si.



Figure 1: (a) Reference structure of CIGS solar cells (b) Proposed structure of CIGS structure.

II. DEVICE STRUCTURE AND SIMULATION

SCAPS-1D was developed at University of Gent, Belgium. The program was originally designed for CdTe and CuInSe2.In proposed structure additional layer p-Si was added which has a band gap 1.12 e V. The performance of cell with new absorber layer was observed using SCAPS-1D simulator. CIGS thickness was ranging from 1.10 to 2 um to investigate performance of ultrathin CIGS solar cell. The cell contains new absorber layer and CIGS thickness of 1um set down on molybdenum with CdS layer having thickness 0.05um and window layer with 0.02um thickness. The proposed structure is shown in the figure.

Parameters	nZnO	nCdS	pCIGS	p-Si
Band gap	3.30 eV	2.45 eV	1.10 eV	1.12 eV
Electron affinity	4.60 eV	4.40 eV	4.50 eV	4.05 eV
Dielectric	9	10	13.60	11.90
constant				
$Nc(cm^{-3})$	2.2×10^{18}	2.2×10^{18}	2.2×10^{18}	2.8×10^{19}
$Nv(cm^{-3})$	1.8×10^{19}	1.8×10^{19}	1.8×10^{19}	2.65×10^{19}

Table 1:	Simulation	parameters	[8]	L
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100	100	100	1450	

Electron	100	100	100	1450
mobility(cm ² /Vs)				
Hole	25	25	25	500
mobility(cm ² /Vs)				
$n,p(cm^{-3})$	$1.0 \mathrm{x} \ 10^{20}$	$1.0x \ 10^{20}$	2.0×10^6	$1.0x \ 10^{20}$
Defect	$1.0 \mathrm{x} \ 10^{14}$			
density(cm ⁻³)				

III. RESULT AND DISCUSSION

1. Effect of Thickness on Cell Performance: The reference structure was simulated using SCAPS-1D simulator. The thickness was varying from 1.1um to 2um using SCAPS-1D simulator. Due to excess of thickness large numbers of photons are absorbed. Due to increase of thickness in absorber layer efficiency also gain from 13.74% to 15.12% for thickness of 2um with fill factor 78.58%, open circuit voltage 0.4797V and short circuit current density 40.10mA/cm². Open circuit voltage and short circuit current density were reduced when thickness of absorber layer was reduced. This may lead to the process of recombination of electrons and holes at back contact. By adding p- Si efficiency had been increased from 14.99% to 19.56%. Thickness of CIGS for new structure was varying from 0.1 um to 1 um, while other parameters remained unchanged. The simulation result showedthat 19.56% efficiencyhad been achieved. When thickness of absorber layer is increased more photons can be absorbed. As a result more hole- electron pairs are generated. The value of Jsc increases from 32.43 mA/cm²to 41.14 mA/cm²and enhance Vocfrom 0.5721 V to 0.5796 V which improve cell efficiency.



Figure 2: Absorber thickness vs. PCE, Jsc, FF, and Voc of proposed Cell

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2. Effect of Operating Temperature: With increase in temperature cell parameters deteriorate. Short circuit current density increases with rise in temperature. The main reason behind this is the reduction of band gap at high temperature. Many photons have much more energy to create pairs of charge carriers. Open circuit voltage reduces with rise in temperature. With increase in temperature reduction of open circuit voltage shows that Voc has dependence on saturation current which decrease with increase in temperature. At very high temperature all parameters would be much more affected would result in degrade the cell performance.





3. Effect of Series Resistance on Cell: R_s had been varied between 0 and 5 Ω cm². The performances of both cells were much more affected by increasing the value of series resistance. This indicates that increase in series resistance affect significantly to efficiency of both solar cells.

Series	Solar cell efficiency without Si	Solar cell efficiency
resistance(Ωcm ²)	layer (1um)	with Si layer(1um)
0	15.12%	19.56%
1	13.74%	18.04%
2	12.43%	16.54%
3	11.14%	15.13%
4	9.89%	13.73%
5	8.90%	12.37%

Table 2: Effect of series resistance on both cell performances

IV. CONCLUSION

The reference structure was simulated and accordingly proposed structure was given with Si as absorber layer. ZnO/CdS/CIGS/Si structure shows efficiency of 19.56% with Voc 0.5796 V, Jsc 41.146218 mA/cm² and FF 82.01%. The proposed structure showed excellent performance with reduced cost as compared to conventional CIGS solar cells.

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